

Waveguide Bragg Gratings and Resonators

JUNE 2016

Outline

Introduction

Waveguide Bragg gratings

- Background
- Simulation challenges and solutions
- Photolithography simulation

Initial design with FDTD

Band structure calculation and effect of geometric parameters

Simulation of the full device using EME

- Waveguide Bragg grating
- Phase shifted Bragg grating

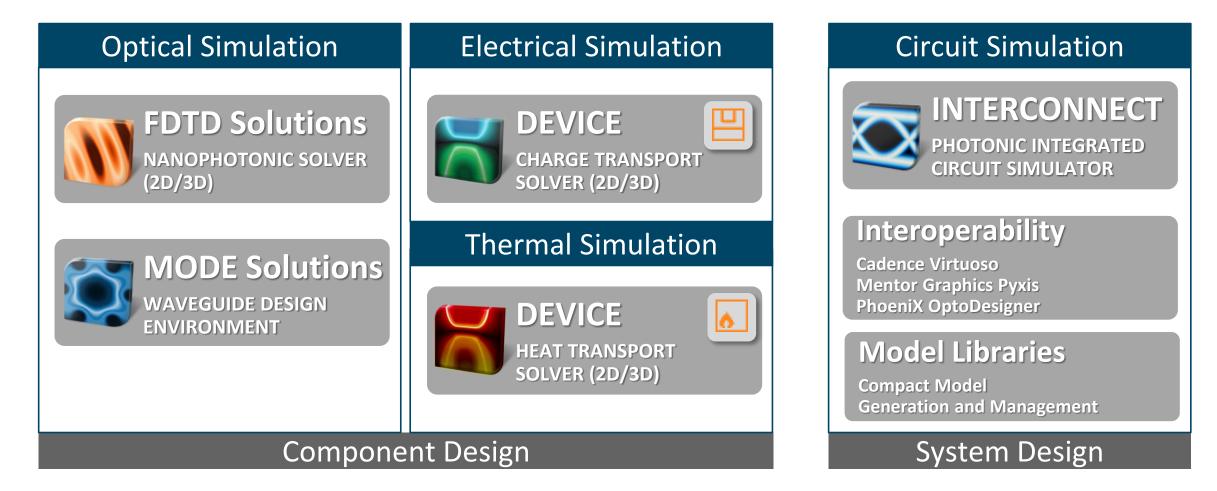
Circuit simulations with INTERCONNECT

- Compact model for WBG
- Hybrid laser

Summary and Q/A



Lumerical Products





Optical Solvers for Different Length Scales

Eigenmode analysis

- MODE Solutions
 - Eigenmode solver (FDE)

Propagation methods

- INTERCONNECT S
 - ID traveling wave
- MODE Solutions
 - 2.5D variational FDTD (varFDTD)
 - Bidirectional eigenmode expansion (EME)
- FDTD Solutions M
 - 2D/3D finite difference time domain (FDTD)

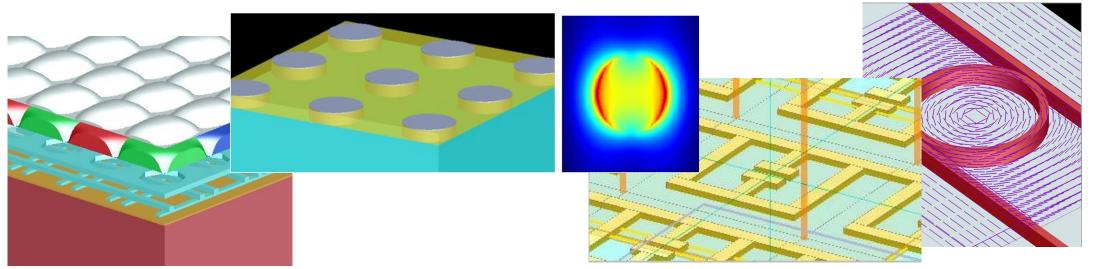
Increasing accuracy Increasing computational cost



Finite Difference Time Domain (FDTD) Solver

Rigorous time domain method for solving Maxwell's equations in complex geometries:

- Few inherent approximations
- General technique: many types of problems and geometries
- Broadband results from one simulation





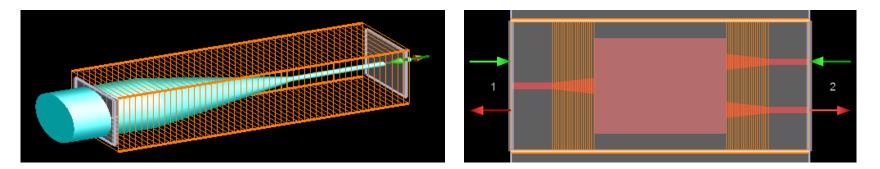
Eigenmode Expansion (EME) Solver

Rigorous frequency domain solver for Maxwell's equations

- Account for multiple-reflection events
- Only one simulation for all input/output modes and polarizations
- Ideal for long passive components: computational cost scales well with propagation distance

Scattering matrix formulation

- Define interfaces and calculate modes
- Boundary conditions applied at each interface





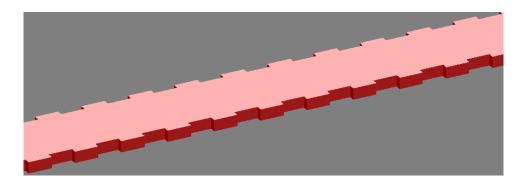
Waveguide Bragg Gratings

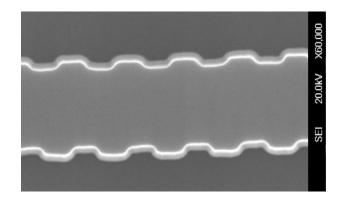


What is a Waveguide Bragg Grating?

1D photonic bandgap structure

- Straight waveguide with a periodic perturbation
- Wavelength specific dielectric mirror
 - ~100% reflection over a range of frequencies
 - ~100% transmission otherwise



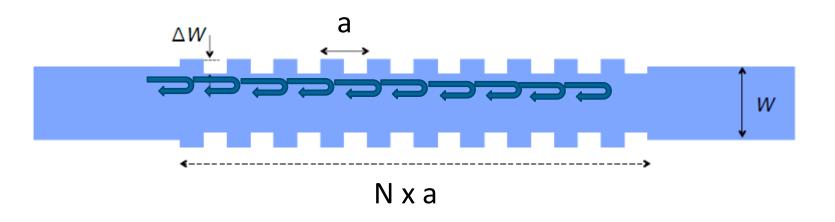




Basic design of a waveguide mirror

Find condition for constructive interference of reflections

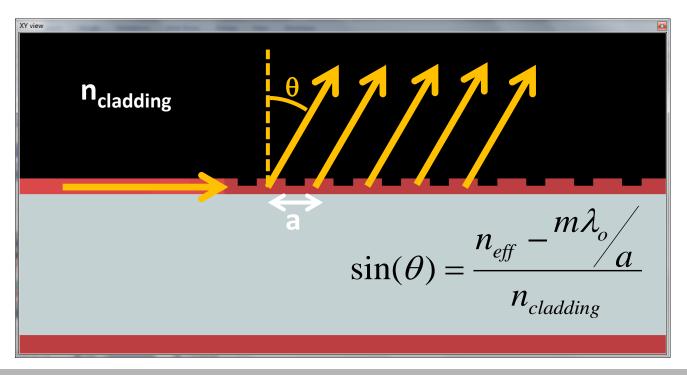
- Wavelenght in the waveguide: $\lambda = \lambda_0 / n_{eff}$
- Reflected waves will be in phase if $2^*a = m^*\lambda$
- Bragg condition for first-order grating (m=1): $\lambda_0 = 2^*a^*n_{eff}$





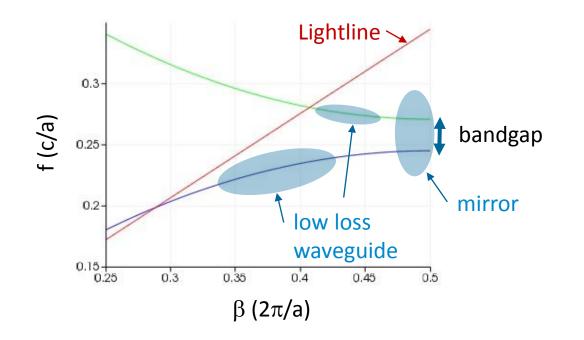
Basic design of a waveguide mirror

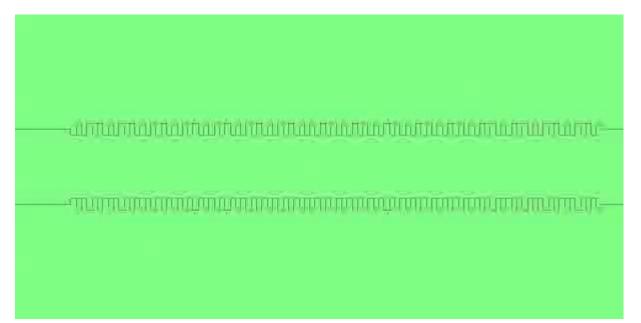
- It is also possible to scatter light out of the structure
- Another constructive interference condition
- Used to design grating couplers





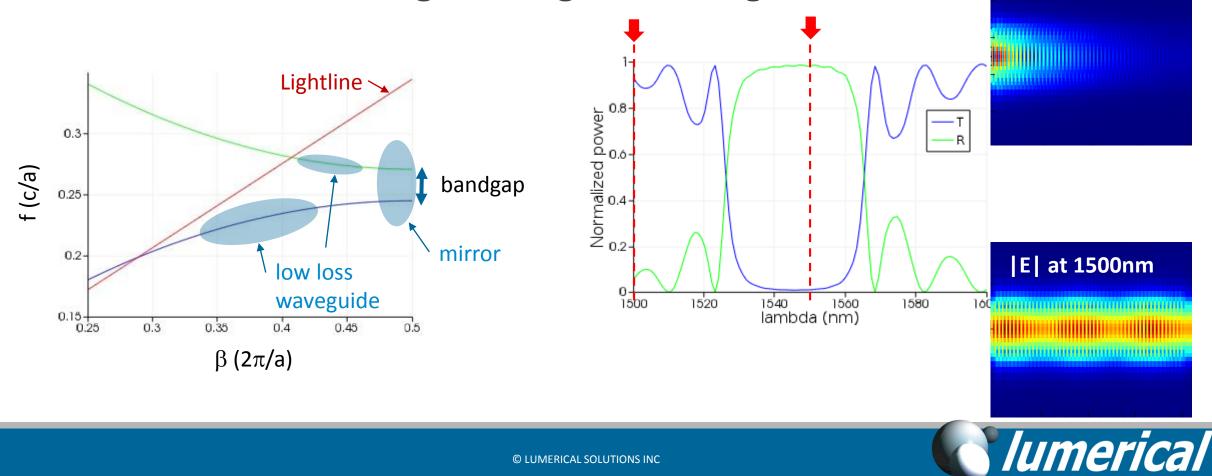
Below the light line, the Bragg grating can selectively transmit or reflect light along the waveguide





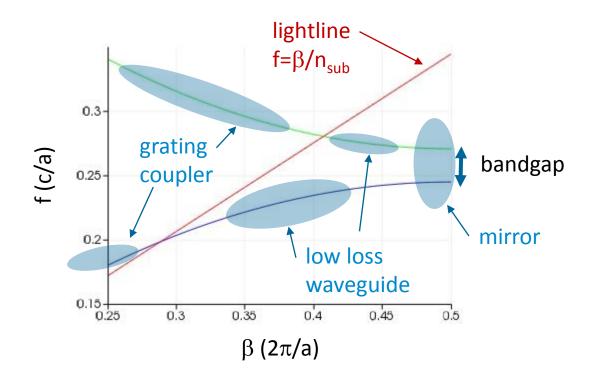


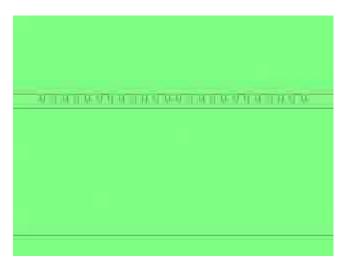
Below the light line, the Bragg grating can selectively transmit or reflect light along the waveguide



E at 1550nm

Above the light line, we can scatter light out of the structure: grating coupler







Simulation Challenges and Solutions

Challenges

- FDTD
 - Simulation size: full device is usually many periods long

EME

- Modes can be very discontinuous
- Many wavelengths required to resolve spectrum: one simulation per wavelength in frequency-domain solvers

Geometry effects

- Lithography effects
- Corrugation depth and misalignment

Initial design with FDTD

- Simulate unit cell with Bloch-periodic boundary conditions
- Calculate center wavelength and bandwidth

Full simulation with EME

- Quickly simulate many periods
- Check convergence by increasing number of modes
- To resolve the spectrum scan grating period length instead of wavelength
- Lithography corrected structure
- Sweeps over corrugation depth and misalignment

Circuit simulations with INTERCONNECT

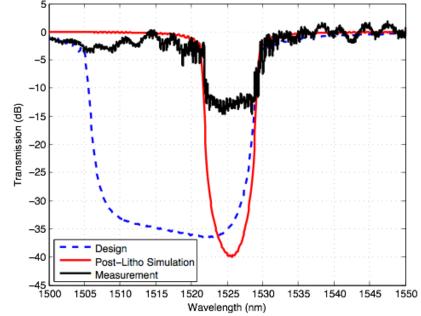


Photolithography Effects

Waveguide Bragg grating designed with 40 nm square corrugations

FDTD simulations of photolithography simulated design matches experimental Bragg bandwidth

 Lithography simulation with Mentor Graphics' Calibre



Xu Wang, et al., "Lithography Simulation for the Fabrication of Silicon Photonic Devices with Deep-Ultraviolet Lithography", IEEE GFP, 2012

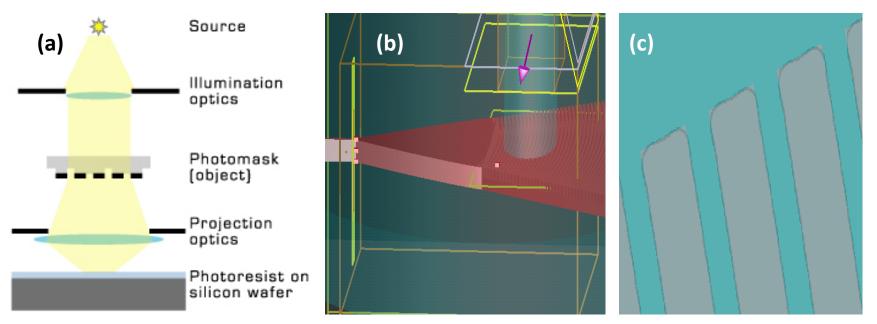
Original Litho simulated



Photolithography simulation

Fraunhoffer diffraction at mask

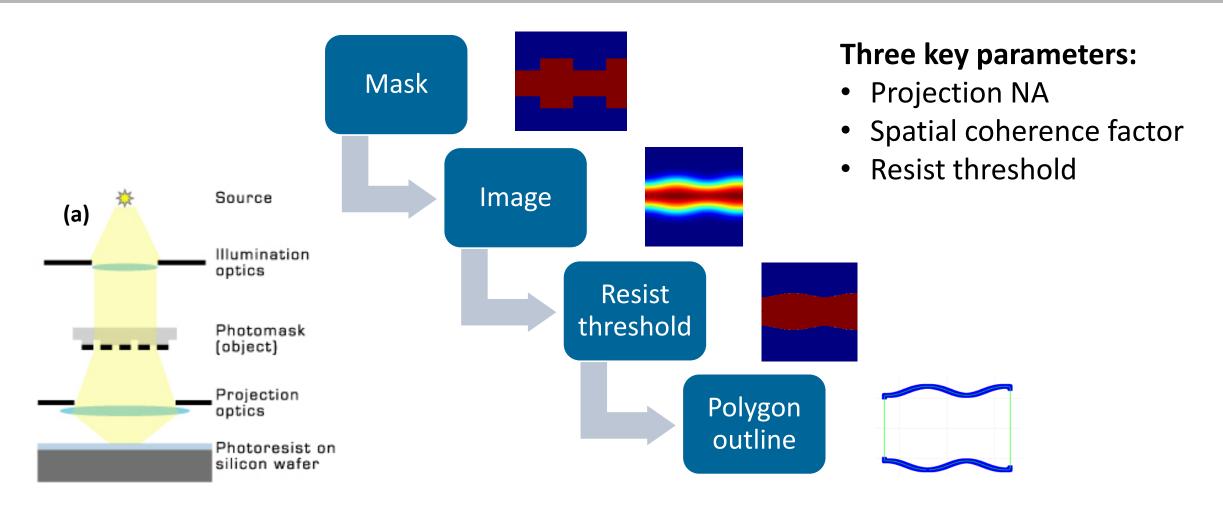
- Infinitely thin metal (ignored plasmonic or polarization effects)
- Simple resist model (defined by a threshold level)



J. Pond, et al., "Design and optimization of photolithography friendly photonic components", Proc. SPIE, vol. 9751, 3/2016.



Photolithography simulation





Initial design with FDTD

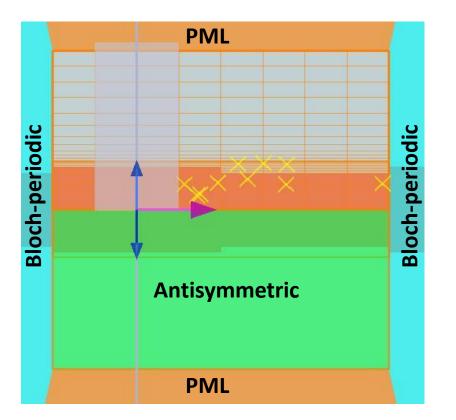


Band structure calculation

Simulate unit cell of Waveguide Bragg grating in FDTD

- Mode source (other sources also possible)
- Bloch-periodic boundary conditions
 - Set appropriate Bloch wavevector $-\pi/a < k_x < \pi/a$
 - Band gap usually at $k_x = \pi/a$
- Calculate spectrum from time monitors

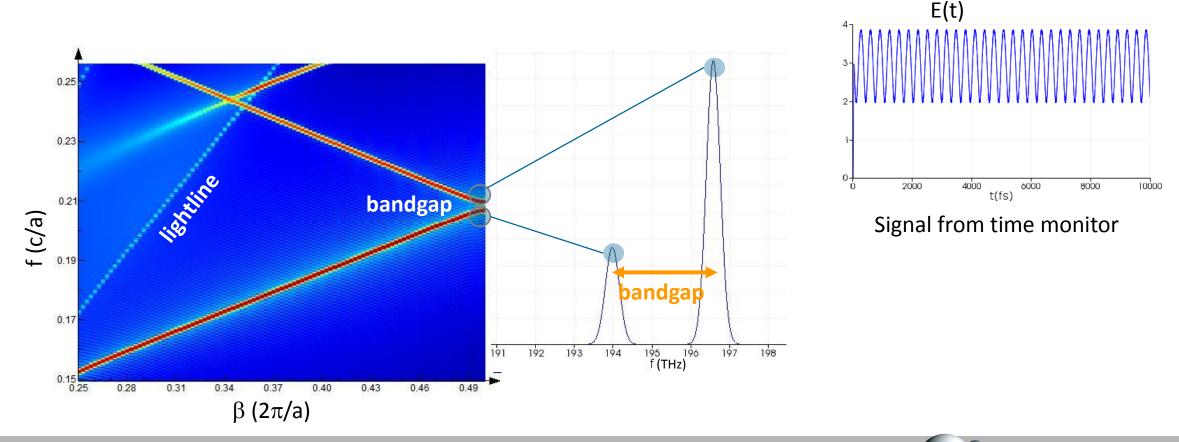
DEMO!



KB example: https://kb.lumerical.com/en/index.html?pic_passive_bragg_initial_design_with_fdtd.html



Sweep over k_x to get full band structure

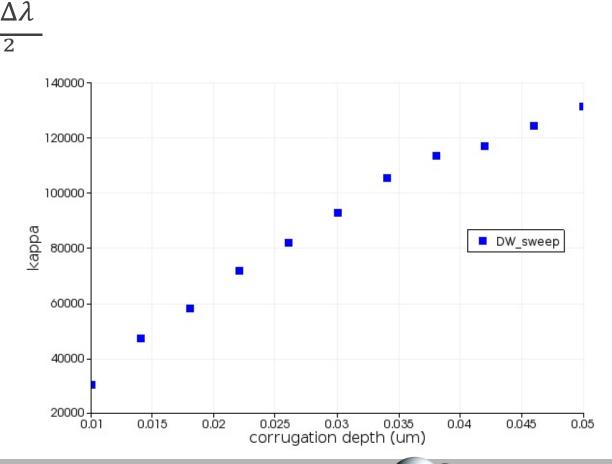




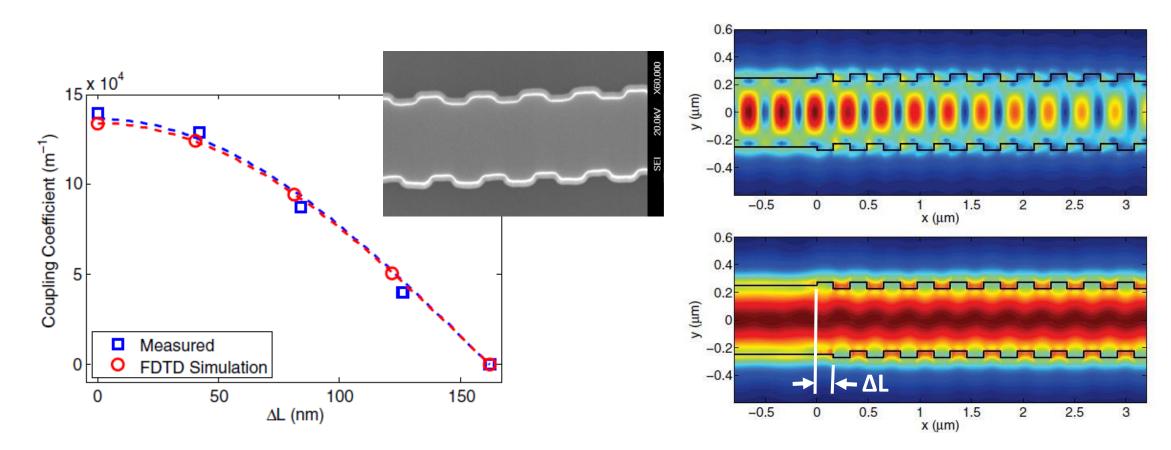
Effect of corrugation depth

Sweep over grating depth

- Coupling coefficient: $\kappa = \frac{\pi n_g \Delta \lambda}{\lambda_o^2}$
 - $\Delta \lambda \rightarrow$ bandwidth
 - $\lambda_0 \rightarrow$ center wavelength
 - $n_g \rightarrow$ group index at λ_0



Effect of misalignment

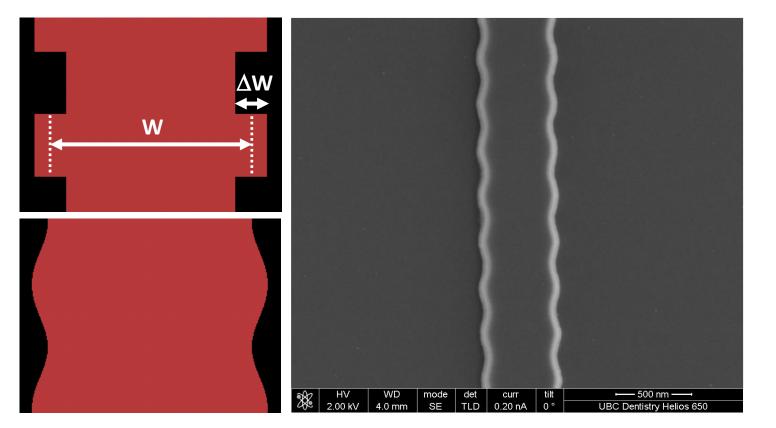


Xu Wang, et al., "Precise control of the coupling coefficient through destructive interference in silicon waveguide Bragg gratings", Optics Letters, vol. 39, issue 19, pp. 5519-5522, 10/2014.



Effects of photolithography

Use script for photolithography simulation



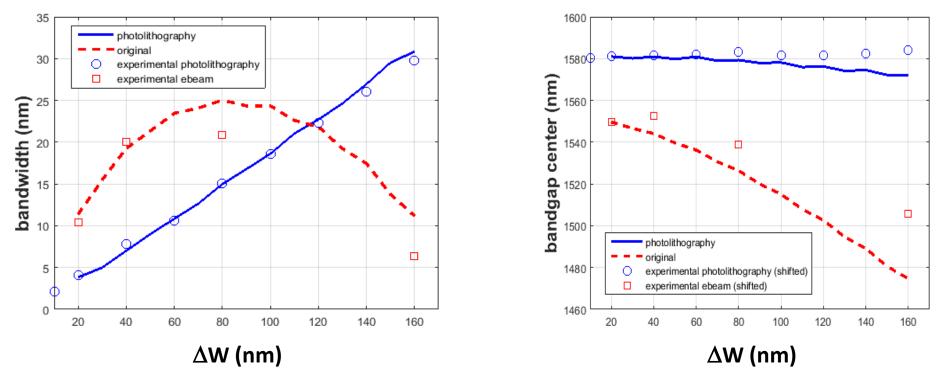
DEMO!

J. Pond, et al., "Design and optimization of photolithography friendly photonic components", Proc. SPIE, vol. 9751, 3/2016.



Effects of photolithography

Excellent agreement between simulation and experimental results:



J. Pond, et al., "Design and optimization of photolithography friendly photonic components", Proc. SPIE, vol. 9751, 3/2016.



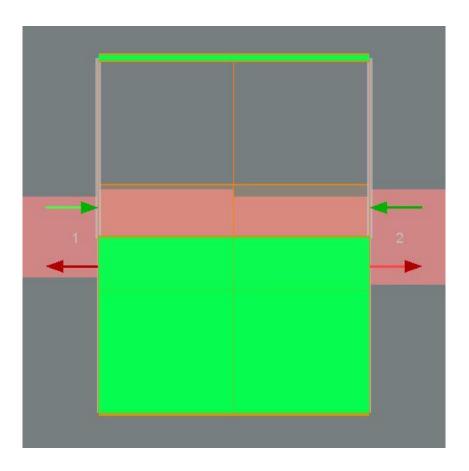
Simulation of Full Device using EME



WBG: Simulation Setup in EME

Without lithography effects

- Two cell groups (one per waveguide thickness)
- One cell per group
- Start with 10 modes in every cell
- Set the number of periods in EME settings

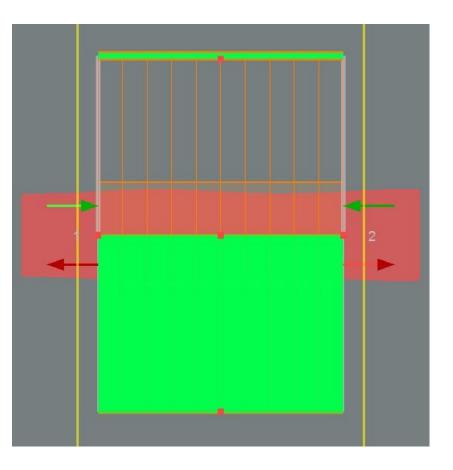




WBG: Simulation Setup in EME

With lithography effects

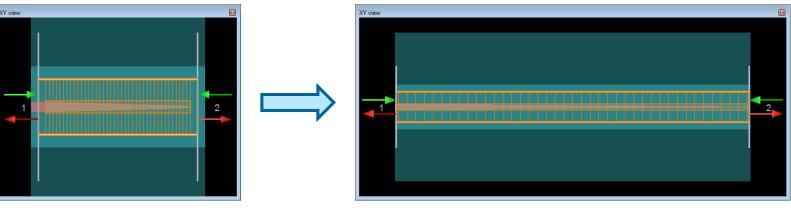
- One cell group for the entire unit cell
- Start with 10 cells to resolve curvature
- Make sure the mesh is fine enough
- Start with 10 modes in every cell
- Set the number of periods in EME settings





Full Spectrum Simulation

The propagation length and number of periods can be modified **without having to recalculate any modes**, and the result can be calculated instantly



10um taper

100um taper



WBG: Full Spectrum Simulation

Brute force method

- Run one simulation per wavelength
- Efficient approach
- Solve device for one reference wavelength
- Stretch or compress each cell to create an equivalent wavelength change and calculate results at all desired wavelengths

Length scale factor:
$$\alpha = 1 + \frac{n_g}{n_{eff}} \left(\frac{\lambda_{ref}}{\lambda} - 1 \right)$$

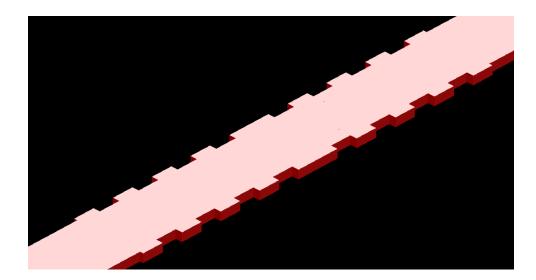




Phase-Shifted Bragg Gratings

Introduce a phase shift in the middle of the grating to create a sharp resonant peak within the stop band

- Sharp filter for integrated optical circuits
- Sensor applications



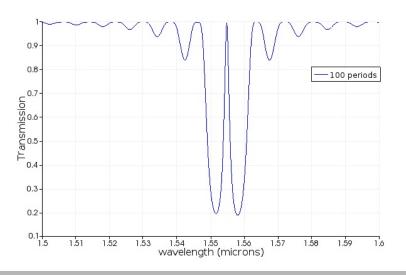
P. Prabhathan, et al., "Compact SOI nanowire refractive index sensor using phase shifted Bragg grating", Optics Express, Vol. 17, No. 17, 2009

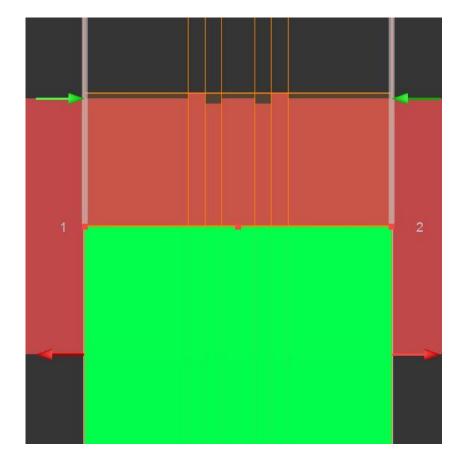


Full Spectrum Simulation

Use same efficient approach as for WBG to get full spectrum

- Period = 320nm
- Number of periods = 100
- Cavity length = 320nm
- Corrugation length = 20nm

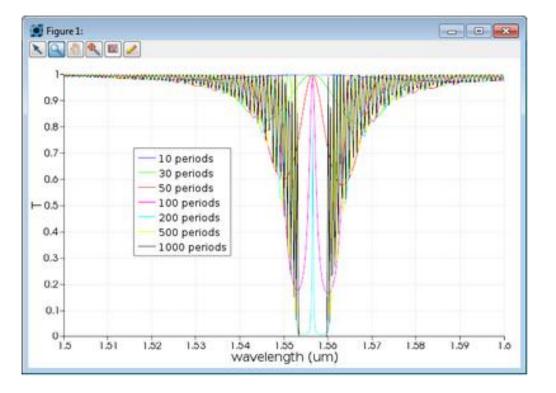




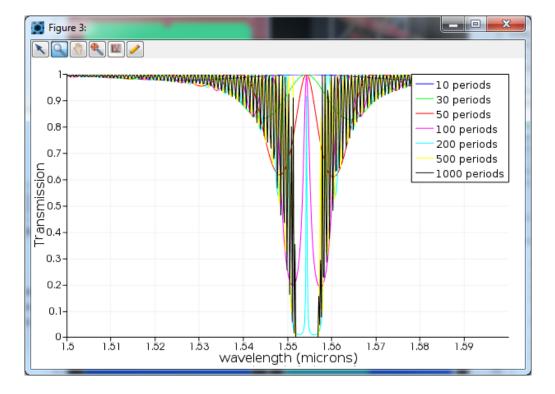


Full Spectrum Simulation

Brute force approach (101 wavelength points)



Fast approach (501 wavelength points)



KB example: <u>https://kb.lumerical.com/en/index.html?pic_passive_bragg_phase_shifted.html</u>



Optimizing with EME

Efficiently optimize devices requiring

- Length scanning such as tapers
- Modifying the number of periods

There are often tricks to avoid the disadvantage of EME when scanning wavelength



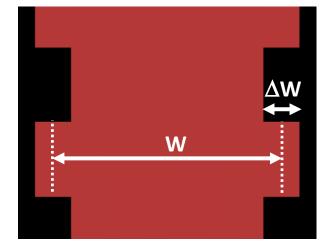
Circuit Simulations with INTERCONNECT



What do we want?

A table that maps our design parameters to bandwidth and operating wavelength

- We can create compact models for PDKs
- Large scale circuit design and simulation becomes easy



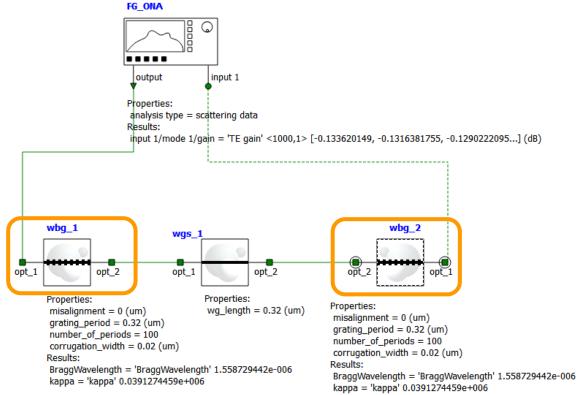
W	ΔW	Bandgap	Operating wavelength
500 nm	40 nm	10 nm	1550 nm
500 nm	50 nm	12 nm	1550 nm

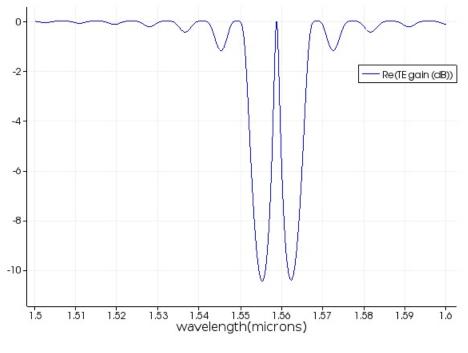


WBG Compact model

WBG PCell (will be available in Lumerical CML)

Quickly simulate phase shifted Bragg grating



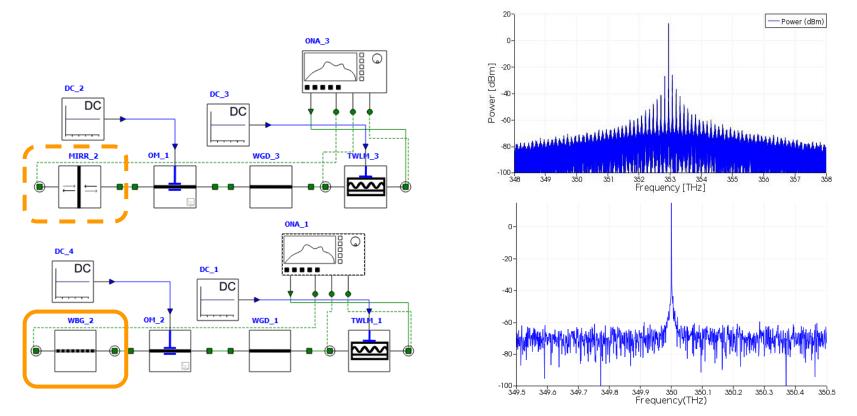






WBG in Hybrid Lasers

WBG selective reflectivity \rightarrow single-mode operation in a laser



More info: https://www.lumerical.com/support/video/modeling_lasers.html



Summary

Waveguide Bragg gratings can be

- Waveguides
- Frequency selective mirrors
- Grating couplers

Simulation with

- FDTD bandstructure of infinite device
- EME finite device, finite device with defect
- INTERCONNECT calibrated traveling wave model

Many applications

- Filters
- Laser mirrors
- Sensors

....



www.lumerical.com

Connect with Lumerical





Contact Us

Questions? kx.lumerical.com

Sales Inquiries: sales@lumerical.com

Evaluate Lumerical tools free for 30 days www.lumerical.com

